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		FOREIGN 1	PATENT DOCUMENTS		
Examiner Initials*	Cite No.	Country Code - Document Number - Kind Code	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Trans.
	AA	JP 2002-508452	03-19-2002		includes English language abstract
	AB	JP 2002-506927	03-05-2002		includes English language abstract
	AC	JP 63-310989	12-19-1988	Shimamura, et al.	includes English language abstract
	AD	JP 2004-137588	05-13-2004	Kumagai, et al.	includes English language abstract
	AE	JP 08-156176	06-18-1996	Kataoka, et al.	includes English language abstract
	AF	JP 2000-261113	09-22-2000	Yamamori, et al.	includes English language abstract

NON PATENT LITERATURE DOCUMENTS							
Examiner Initials*	Cite No.	(Include Author, Title, Date, Pages, Etc.)					
	AG	Japanese language Office Action in a counterpart foreign					
		application dated July 6, 2009 (4 sheets)					
	AH	Japanese language Office Action in a counterpart foreign					
		application dated May 8, 2009 (4 sheets)					
	AI	Japanese language Office Action in a counterpart foreign					
		application dated April 9, 2009 (3 sheets)					
	AJ Voltammetric and morphological characterization of						
		electrodeposition from non-cyanide electrolyte", M.R.H. DE ALMEIDA, et al., Journal of Applied Electrochemistry, Vol.					
		32, pp. 763-773 (2002)					
EXAMINER	SIGNA	TURE DATE CONSIDERED					

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